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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/519,935	12/29/2004	Fumihiro Arakawa	123746	5086
25944 OLIFF & BERI	7590 12/11/200 RIDGE, PLC	EXAMINER		
P.O. BOX 3208	350	NGO, HUNG V		
ALEXANDRIA, VA 22320-4850			ART UNIT	PAPER NUMBER
			2831	
			MAIL DATE	DELIVERY MODE
			12/11/2008	PAPER

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

	Application No.	Applicant(s)			
	10/519,935	ARAKAWA ET AL.			
Office Action Summary	Examiner	Art Unit			
	Hung V. Ngo	2831			
The MAILING DATE of this communication appeariod for Reply	pears on the cover sheet with the c	correspondence address			
A SHORTENED STATUTORY PERIOD FOR REPL WHICHEVER IS LONGER, FROM THE MAILING D - Extensions of time may be available under the provisions of 37 CFR 1.1 after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period - Failure to reply within the set or extended period for reply will, by statute Any reply received by the Office later than three months after the mailin earned patent term adjustment. See 37 CFR 1.704(b).	PATE OF THIS COMMUNICATION 136(a). In no event, however, may a reply be tinwill apply and will expire SIX (6) MONTHS from e, cause the application to become ABANDONE	N. nely filed the mailing date of this communication. D (35 U.S.C. § 133).			
Status					
Responsive to communication(s) filed on <u>08-0</u> This action is FINAL . 2b) ☑ This 3) ☐ Since this application is in condition for alloward closed in accordance with the practice under the practice under the practice.	s action is non-final. ince except for formal matters, pro				
Disposition of Claims					
4) Claim(s) 1-8 and 10-25 is/are pending in the a 4a) Of the above claim(s) is/are withdra 5) Claim(s) is/are allowed. 6) Claim(s) 1-8 is/are rejected. 7) Claim(s) 10-25 is/are objected to. 8) Claim(s) are subject to restriction and/o	wn from consideration.				
9)☐ The specification is objected to by the Examiner.					
10) The drawing(s) filed on is/are: a) accomplicant may not request that any objection to the Replacement drawing sheet(s) including the correct 11) The oath or declaration is objected to by the Expression 11.	drawing(s) be held in abeyance. Section is required if the drawing(s) is ob-	e 37 CFR 1.85(a). jected to. See 37 CFR 1.121(d).			
Priority under 35 U.S.C. § 119					
 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 					
Attachment(s) 1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO/SB/08) Paper No(s)/Mail Date	4) Interview Summary Paper No(s)/Mail Da 5) Notice of Informal F 6) Other:	ate			

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DETAILED ACTION

Double Patenting

The nonstatutory double patenting rejection is based on a judicially created doctrine grounded in public policy (a policy reflected in the statute) so as to prevent the unjustified or improper timewise extension of the "right to exclude" granted by a patent and to prevent possible harassment by multiple assignees. A nonstatutory obviousness-type double patenting rejection is appropriate where the conflicting claims are not identical, but at least one examined application claim is not patentably distinct from the reference claim(s) because the examined application claim is either anticipated by, or would have been obvious over, the reference claim(s). See, e.g., *In re Berg*, 140 F.3d 1428, 46 USPQ2d 1226 (Fed. Cir. 1998); *In re Goodman*, 11 F.3d 1046, 29 USPQ2d 2010 (Fed. Cir. 1993); *In re Longi*, 759 F.2d 887, 225 USPQ 645 (Fed. Cir. 1985); *In re Van Ornum*, 686 F.2d 937, 214 USPQ 761 (CCPA 1982); *In re Vogel*, 422 F.2d 438, 164 USPQ 619 (CCPA 1970); and *In re Thorington*, 418 F.2d 528, 163 USPQ 644 (CCPA 1969).

A timely filed terminal disclaimer in compliance with 37 CFR 1.321(c) or 1.321(d) may be used to overcome an actual or provisional rejection based on a nonstatutory double patenting ground provided the conflicting application or patent either is shown to be commonly owned with this application, or claims an invention made as a result of activities undertaken within the scope of a joint research agreement.

Effective January 1, 1994, a registered attorney or agent of record may sign a terminal disclaimer. A terminal disclaimer signed by the assignee must fully comply with 37 CFR 3.73(b).

Claims 1, 8 is rejected on the ground of nonstatutory obviousness-type double patenting as being unpatentable over claim 1 of U.S. Patent No. 7,304,250. Although the conflicting claims are not identical, they are not patentably distinct from each other because it would have been obvious to one of ordinary skill in the art at the time the invention was made to modify the mesh layer of Pat 7,304,250 by employing specific width for intended use, since such a modification would have involved a mere change in the size of a component. A change in size is generally recognized as being within the level of ordinary skill in the art. In re Rose, 105 USPQ 237 (CCPA 1955).

Claims 2, 3 are rejected on the ground of nonstatutory obviousness-type double patenting as being unpatentable over claim 1 of U.S. Patent No. 7,304,250 in view of Ryohei et al (JP 2000-286594).

The teaching of as discussed above does not disclose the radius of curvature being 1.5-3 times the thickness of the conductive structure.

Ryohei et al teach the use of a radius of curvature for the conductive structure (2) for improving visibility. It would have been obvious to one of ordinary skill in the art at the time the invention was made to modify the structure of Takahashi et al by employing the radius of curvature for improving visibility and it would have been obvious to one of ordinary skill in the art at the time the invention was made to optimize the structure of Pat No 7,304,250 by employing 1.5-3 times the thickness of the conductive structure, since it has been held that discovering an optimum value of a result effective variable involves only routine skill in the art. In re Boesch, 617 F.2d 272, 205 USPQ 215 (CCPA 1980).

Claims 4-7 are rejected on the ground of nonstatutory obviousness-type double patenting as being unpatentable over claim 1 of U.S. Patent No. 7,304,250 in view of Takahashi et al (US 2004/0074655).

The teaching of as discussed above does not disclose the feature of claims 4-7

Takahashi et al disclose an electromagnetic shielding sheet comprising: a transparent base (2), and a meshed conductive structure (4, 5) laminated to one of the surfaces of the transparent base; wherein the conductive structure has

lines having straight parts of a width in the range of $C(I \pm 30\%)[0144]$, where C is a predetermined value.

Re claim 4, wherein the widths of the straight parts of the lines an inner part of the meshed conductive structure surrounded by a peripheral part of a width corresponding to 1 to 50 meshes or a peripheral part of a width in the range of 0.15 to 15 mm are in the range of $C(I \pm 30\%)$, where C is a predetermined value (L1=2mm) [0144].

Re claim 5, wherein the widths of the straight parts of the lines of the conductive structure are in the range of 5 to 25 microns, and the lines are arranged at pitches in the range of 150 to 500 microns [0152].

Re claim 6, wherein the conductive structure is a metal layer [0070].

Re claim 7, wherein at least one of the surfaces of the conductive structure is processed by a blackening treatment [0139].

It would have been obvious to one of ordinary skill in the art at the timethe invention was made to adopt the feature of Takahashi et al and combine with the feature of Pat No 7,304,250 for intended use.

Allowable Subject Matter

Claims 10-25 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

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Any inquiry concerning this communication or earlier communications from the examiner should be directed to Hung V. Ngo whose telephone number is (571) 272-1979. The examiner can normally be reached on Monday to Friday 9:00-5:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Diego Gutierrez can be reached on (571) 272-2800 EXT 31. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

/Hung V Ngo/ Primary Examiner, Art Unit 2831